

CCEM workshop on “Radiofrequency and microwave metrology: recent developments and challenges” to be held at the BIPM, 27 March 2019

Venue: Pavillon du Mail, BIPM, Sèvres, France

Workshop Programme

- 9:00 Opening by Markus Zeier, chair of the CCEM working group on radio-frequency quantities, GT-RF
- 9:20 “*S-Parameter measurements in coaxial systems*”, Johannes Hoffmann, METAS, Switzerland
- 10:10 “*Plasmonic and photonic technologies for mm-wave wireless communications*”, Maurizio Burla, ETH Zürich, Switzerland
- 11:00 Coffee break
- 11:40 “*Industrial metrology challenges induced by 5G*”, Michael Dieudonné, Keysight Technologies, Belgium
- 12:30 Lunch
- 13:30 “*Application of Modern Quasi-Optical Design and Manufacturing Techniques to mm-wave Remote Sensing Applications - both Active and Passive*”, Richard Wylde, Thomas Keating Ltd, UK
- 14:20 “*High frequency characterization at sub-micrometer scales using on-wafer and scanning probe microscopy techniques*”, Gilles Dambrine, Univ. of Lille, France
- 15:10 Tea break
- 15:40 “*Towards a quantum standard for radio-frequency electric fields*”, Song Zhenfei, NIM, China
- 16:30 Closing discussion
- 17:00 End of workshop